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APPLICATION NO.

INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)

APPLICANT Naveen Chopra et al.

FILING DATE

GROUP ART UNIT

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		U.S. PATENT DOG			
EXAMINER INITIAL	DOCUMENT NUMBER	PUBLICATION DATE	NAME OF PATENTEE	CLASS	SUB CLASS
tt	4,021,364	5/3/77	Speiser et al.	252	316
	4,937,119	6/26/90	Nikles et al.	428	64
	5,824,337	10/20/98	Mullen	424	450
	5,429,826	7/4/95	Nair et al.	424	501
	5,536,490	7/16/96	Klaveness et al.	424	9.52
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	5,961,804	10/5/99	Jacobson et al.	204	606
	5,930,026	7/27/99	Jacobson et al.	359	296
	6,067,185	5/23/00	Albert et al.	359	296
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	5,344,594	9/6/94	Sheridon	264	4.1
	5,723,204	3/3/98	Stefik	428	206
	6,488,870	12/3/02	Chopra et al.	264	4.1
V	6,492,025	12/10/02	Chopra et al.	428	402.21

FOREIGN PATENT DOCUMENTS

COUNTRY	DOCUMENT NUMBER	PUBLICATION DATE	NAME OF PATENTEE OR APPLICANT	TRANSLATION Y/N

OTHER DOCUMENTS (Including Author (in CAPS), Title, Publication Date, Pages, etc.)

#	"Kirk-Othmer Encyclopedia of Chemical Technology," Vol. 15, pp. 470-493 (3rd Edition 1981).				
	David F. O'Brien et al., "Polymerization of Preformed Self-Organized Assemblies," ACC. CHEM. RES. Vol. 31, pp. 861-868 (1998).				
	Mark Summers et al., "Polymerization of Cationic Surfactant Phases" Vol.17 LANGMUIR pp. 5388-5397 (2001).				
	Naveen Chopra et al., U.S. Application Serial No. 09/723,049 (Attorney Docket No. D/A0427) titled "MICROCAPSULE COMPOSITION".				
	Naveen Chopra et al., U.S. Application Serial No. 09,723,187 (Attorney Docket No. D/A0677) titled "ENCAPSULATION PROCESS".				

EXAMINER

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